Microscopes

Model: XJP-6A, Metallurgical



Inverted Metelugical Microscope is suitable to observe the object. It is achromatic objectives & wide-field eyepieces.

It provides clear & high-contrast picture, & with polarizer device, it is the ideal instrument in research work in metallography, mineralogy, precfsion engineering, electronics etc. it's suitable for scientific research, teaching demonstration, in the colleges & factory. Note: in this table,

" ■" denotes a standard attachment,
" O" denotes an optional accessory.
Desighn change: To keep pace with
technological advances, we have
reserved the right to make desighn
modifications & changes
without notice.

Package dimension: 665mm x 310mm

Net weight: 14kg Gross weight: 19kg

Order No.	.,	Standard Outfits		
	Item	XJP-6	XJP-6A	
	Main Body			
SO9	Mechanical stage with a stroke of 75			
	by 50 & size of 180 by 155		_	
EP10	Plan eyepiece 10X-18			
EP12.5	Plan eyepiece 12X-14			
EH5	Huygenian ocular 5X-20	00 00		
EW10	Plan eyepiece 10X-20	00 00		
Epr10b	Plan reticle eyepiece 10X-14	- -		
B-OAr4	Achromat objective 4/0.10 ■			
M-OA10	Achromat objective 10/0.25			
M-OSPr40	S-plan achromat objective 40/0.65			
M-OAor100	Achromat objective 100/1.25oil			
B-OPr2.5	Plan achromat objective 2.5/0.07	0	0	
B-OPr4	Plan achromat objective 4/0.10		0	
M-OPr10	Plan achromat objective 10/0.25			
M-OPr20	Plan achromat objective 20/0.35	0		
M-OPr40a	Plan achromat objective 40/0.65			
M-OSPor100	S-plan achromat objective 100/1.25 oil			
9J-6	Stage plate(1)			
9J-7	Stage plate(2)			
9J-8	Stage plate(3)			
9J-9	Stage plate(4)	0	0	
9J-11	Stage plate holder			
TBR03	Rotating binocular head(45oC)			
LH01	Lamp housing			
	Halogen lamp 6V30W			
PO02	Polarizer			
PA01	Analyzer			
CL02	Specimen clamps			
9J.7	Photo adaptor	0	0	
EPHp5	Photo eyepiece S5X	0	0	
EPHp6.3	Photo eyepiece \$6.3X	0 0		
EPHp0.65	Video eyepiece 0.65X O		0	
1	Metallurgical microphotography equipments	0	0	
	35mm DF camera with shutter release	Ö	Ö	
SC03	Specimen holder	0	0	
	Stage micrometer (division 0.01mm)	0	0	

Model: XJL-101A, Wafer inspection Microscopes



XJL-101 series the reflected light microscope is suitable to observe the microscopical surfaces of non-transparent object. It is equipped with large move range stage, vertical illumination, plan achromatic objectives and wide-field eyepieces. It provides clear and high-contrast picture, & with polarizer device, it is the ideal instrument in research work in metallography, mineralogy, precfsion engineering, electronics etc. it's suitable for scientific research, teaching demonstration, in the colleges & factory.

Model	•			X.IL -101	XJL-101A
Eyepieces	I	WF10X(Ø18mm)		X02 707	1017
	Wide Field	WF16X(Ø11mm)		0	0
	Plan Dividing	10X(0.10mm/div)		0	0
Objectives	Plan achromatic (No cover glass)	Magnification/N.A	Work distance		
		PL5X/0.12	18.3		
		PL10X/0.25	8.9		
		PL25X/0.40	8.7		
		PL40X/0.60	3.7		
		PL50X/0.70	2.02	0	0
		PL80X/0.80	0.96		
Eyepieces Tube	Trinocular	Compensation (inc Including a	clination of 30°) nalyzer		
Stage	Size: 250x250mm can be move quickly. Move Range: 153x153mm				
	Size: 274x274mm can be move quickly. Move Range: 203x203mm				
Nosepiece	Backward inner locating on ball bearing	Quintuple			
CCD Camera Accessories	0.4xCCD Camera adapter		0	0	
	CCD Camera adapter		0	0	
	0.5xCCD Camera adapter with dividing		0	0	
	CCD Camera		0	0	
Illumination unit	Vertical illuminator 6V 20W halogen lamp. adjustable brightness, with polarizer				
Dig. Camera Adapter	CCD camera and accessories			0	0